FIG. 1A

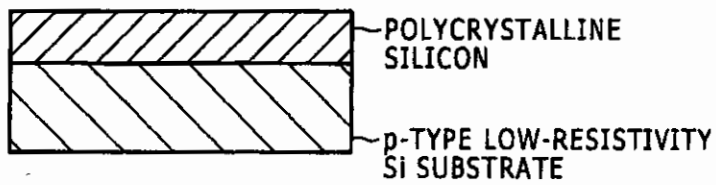


FIG. 1B

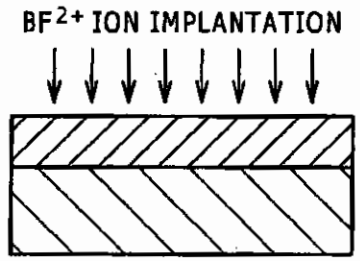


FIG. 1C

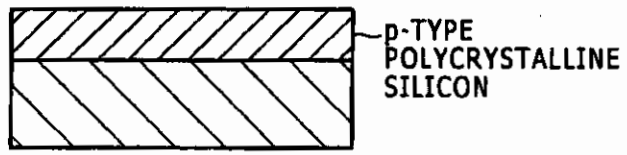


FIG. 1D

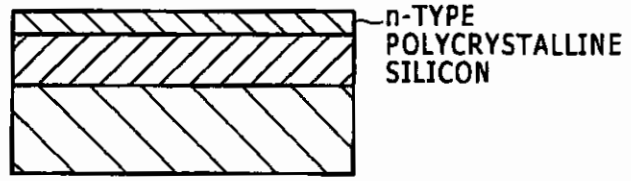


FIG. 1E

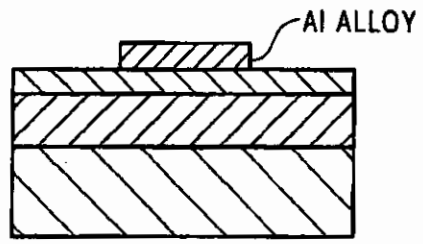
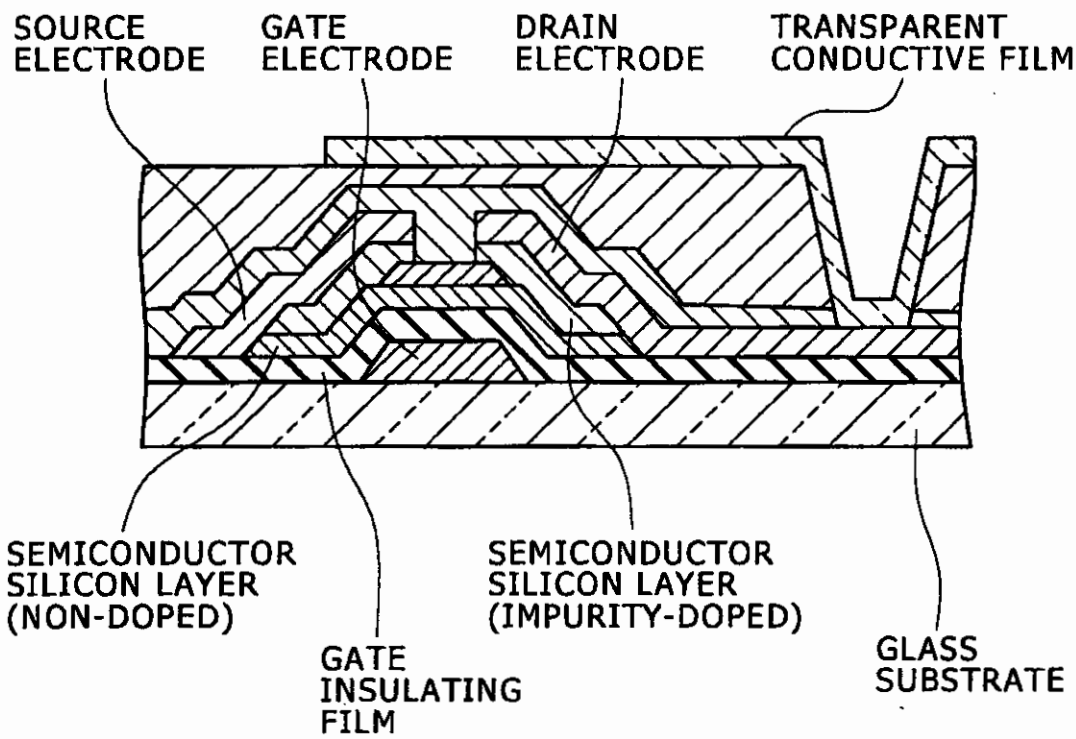


FIG. 2


SOURCE ELECTRODE
GATE ELECTRODE
DRAIN ELECTRODE
TRANSPARENT CONDUCTIVE FILM
SEMICONDUCTOR SILICON LAYER (NON-DOPED)
GATE INSULATING FILM
SEMICONDUCTOR SILICON LAYER (IMPURITY-DOPED)
GLASS SUBSTRATE